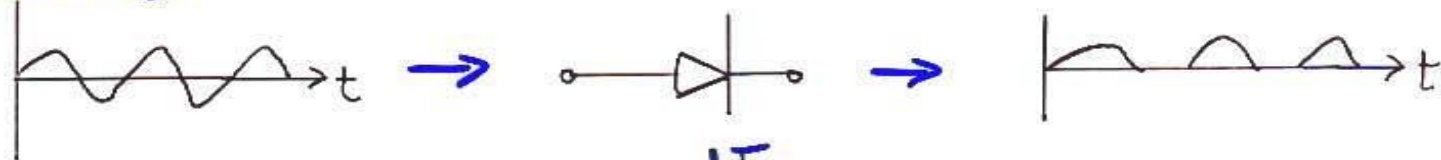


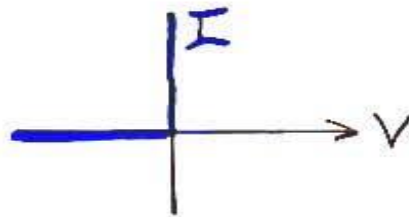
P-N Junction Applications

Basis for important devices

- 1) Rectifier - conducts current in 1 direction only
($V > 0$)



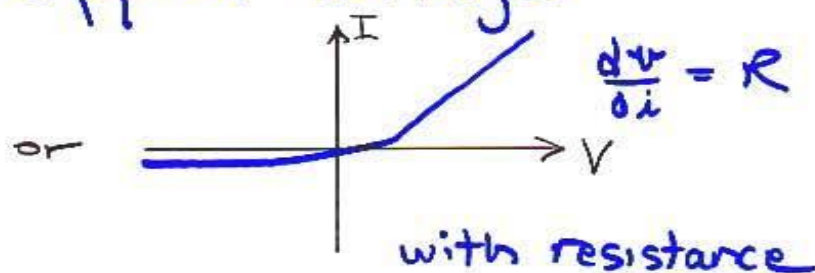
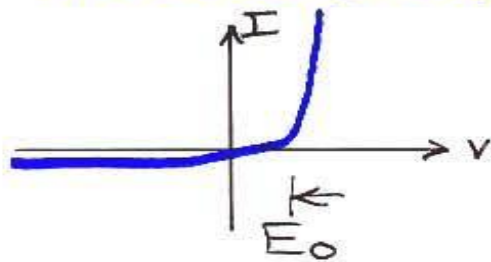
Ideal Diode:



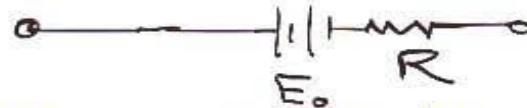
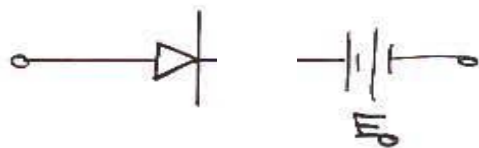
$V < 0$: Open

$V > 0$: Short

Non-Ideal Diode : Offset voltage



with resistance



Piece-wise linear approximations of diode.

Design Considerations

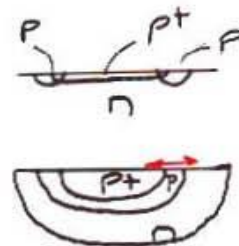
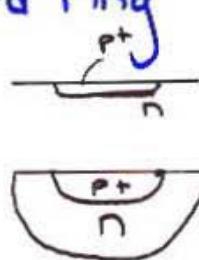
a) Large band gap

- n_i small $\rightarrow I_0$ reverse saturation small
- Can operate at high T since n_i increases small
- higher break down voltage V_{br}
(but E_0 increases)

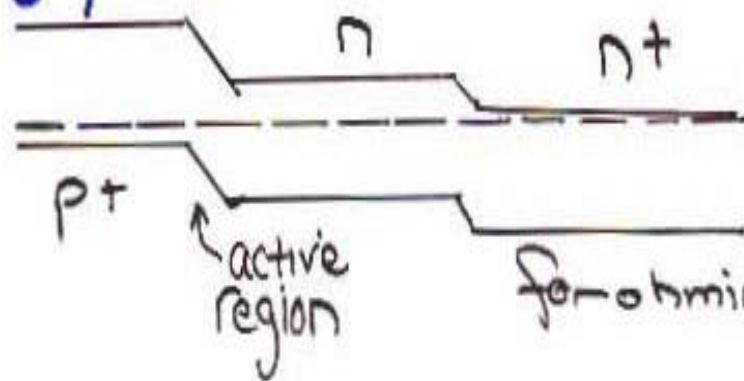
b) Low doping

- Increase V_{br} (in lightly-doped side)
- To offset increased R , make A large and L small

c) Beveled edge/guard ring

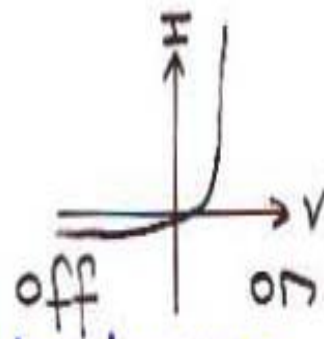


d) Highly doped ohmic contacts



lowers resistance
and voltage across
all but p+n
transition region
and n region.

2) Switching Diode



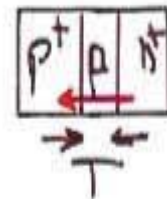
(well, almost)

Minimize response time between on/off states

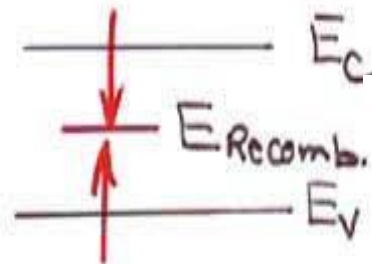
Need:

- a) Very low stored charge
- b) Very short carrier lifetime (τ_n, τ_p)

a) How? Shorten lightly-doped neutral regions
Less charge in smaller volume.



b) How? Add recombination centers.

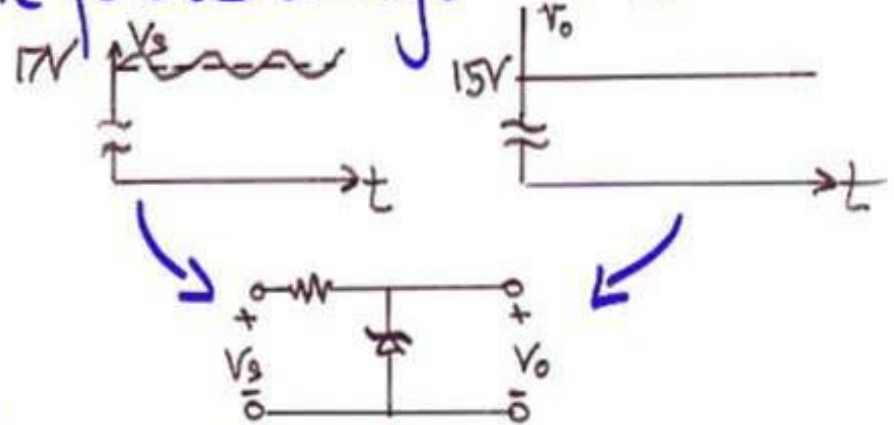
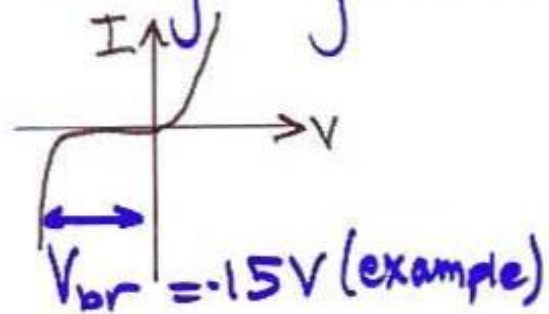


example:
Au in Si
 10^{15} cm^{-3}

$\tau_p \sim 0.01 \mu\text{sec}$

3) Breakdown Diode (Zener effect - tunneling)

Voltage regulators, reference voltage diodes



Design in specific voltage.

4) Varactor Diode (Variable Reactor (Voltage-variable capacitor))

Recall: $C = C(V)$

$$C_j = V_r^{-1/2} \quad \text{abrupt} \quad V_r \gg V_0$$

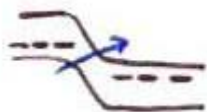
$$C_j = V_r^{-n} \quad \text{Linearly graded} \quad n = \frac{1}{3}$$

Can be used in resonant circuit
→ vary ω with applied V

$$\omega_r = \frac{1}{\sqrt{LC}} \propto V_r \quad \text{for } n=2 \quad (\text{hyperabrupt})$$

Use in place of bulky variable plate capacitors.
Other applications: active filters, μ wave mult.

5.) Tunnel Diodes (p. 486ff. 5th ed.)



Like Zener diode, but doesn't require large V_r to get band overlap

Also — Negative dV/dI !

key: Requires degenerate semiconductors

So far: semiconductors N_a or $N_d \ll$ atomic density
($\approx 10^{22} \text{ cm}^{-3}$)
so dopants don't interact.

At high concentrations ($\geq 10^{19} - 10^{20} \text{ cm}^{-3}$)

→ Dopants overlap & interact

→ Form a band ($N_a, N_d > N_c, N_v$)

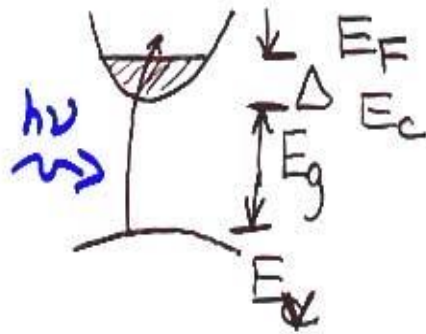
→ Overlaps E_c and E_v

E_F moves into conduction (Valence) band



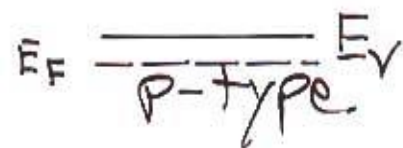
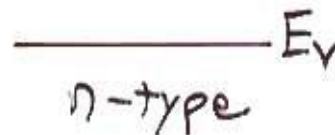
Discrete Broad Degenerate
Increasing n-doping \rightarrow

Discrete Broad Degenerate
Increasing p-doping \rightarrow



No absorption until $E_g + \Delta$
(Burstein Effect)

Band Diagram
for degenerate
semiconductors:



Band Diagram

for degenerate
semiconductors:

$$E_F \text{ --- } E_c$$

$$\text{--- } E_c$$

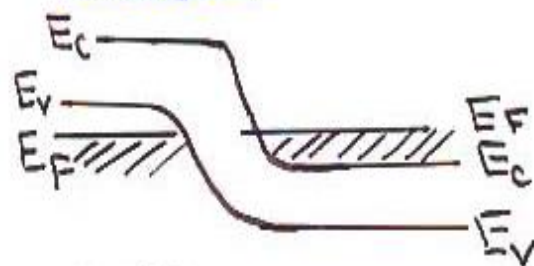
$$\text{--- } E_v$$

n-type

$$E_F \text{ --- } E_v$$

p-type

Tunnel diode involves p-n junction with
both sides degenerate.



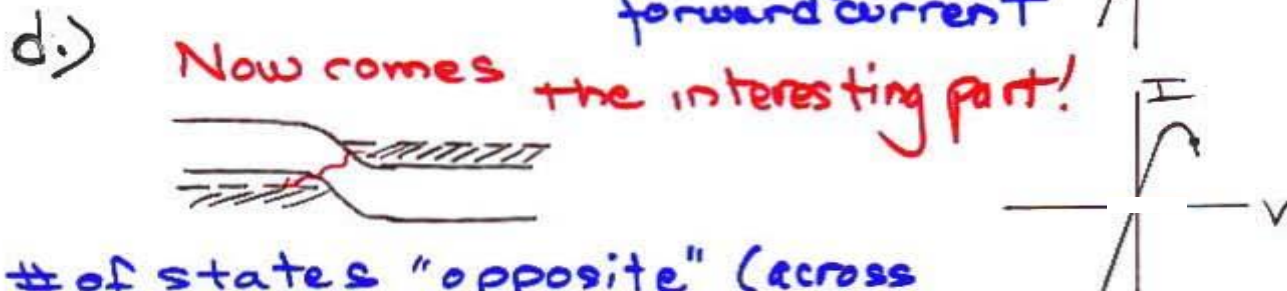
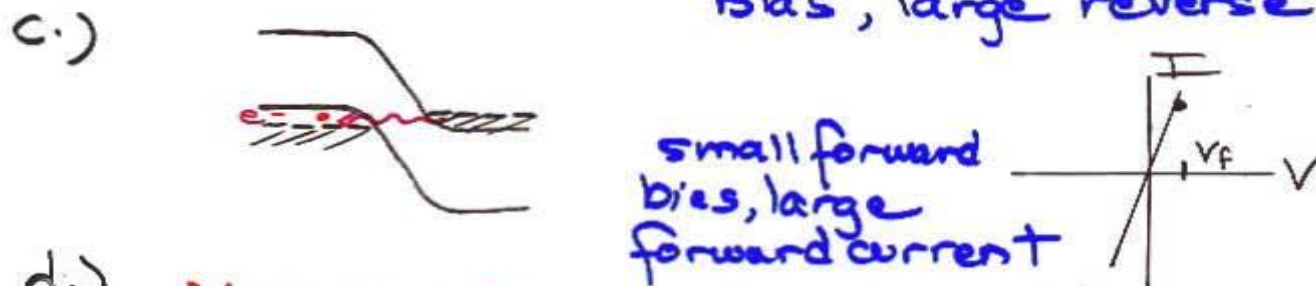
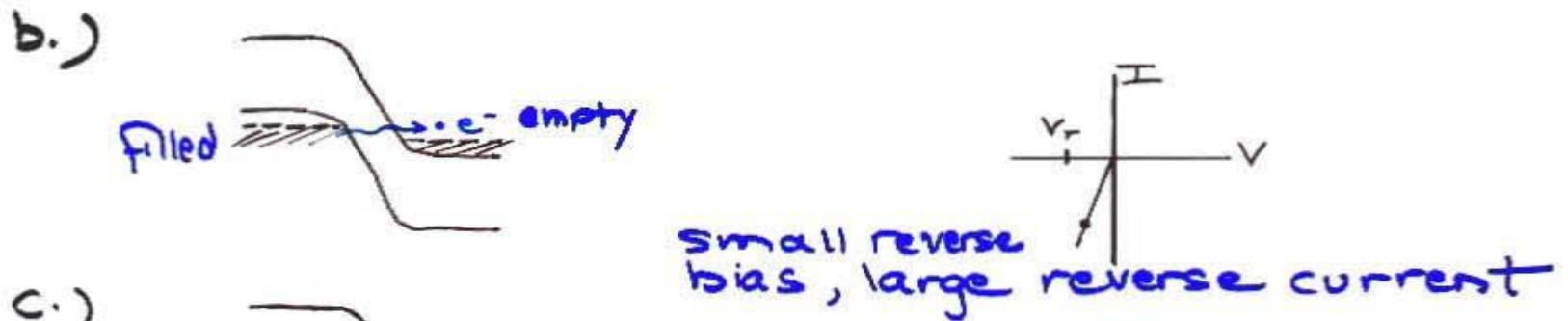
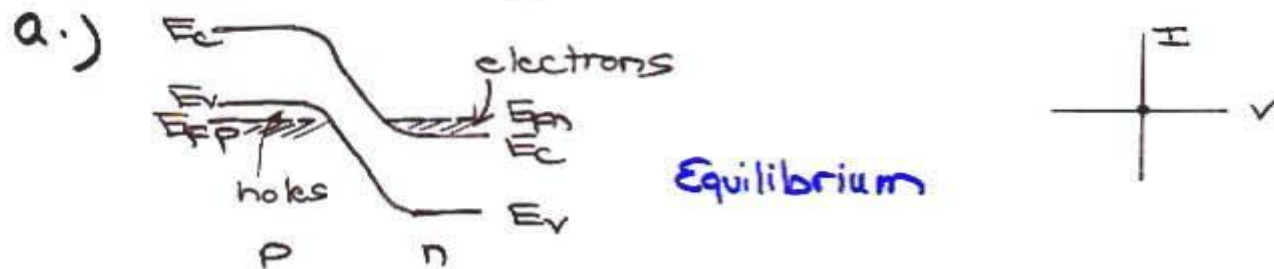
Equilibrium

→ Bands overlap even
with $V=0$!

so low voltage can give tunneling
versus large V_r needed with Zener

Filled and empty states separated by thin barrier
→ Tunneling

Band Diagrams and I-V

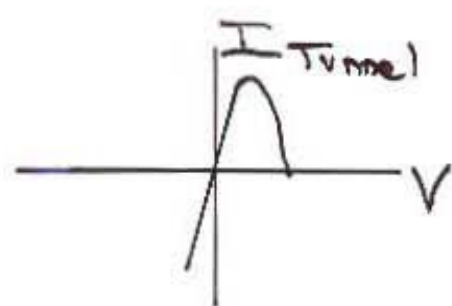
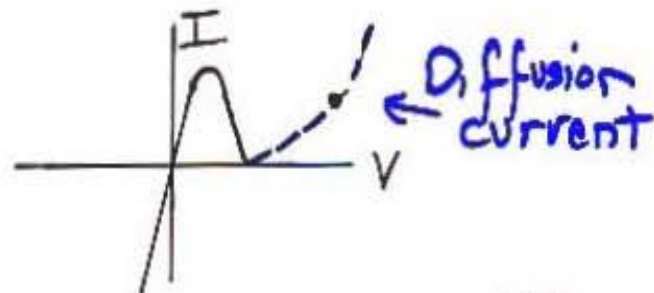
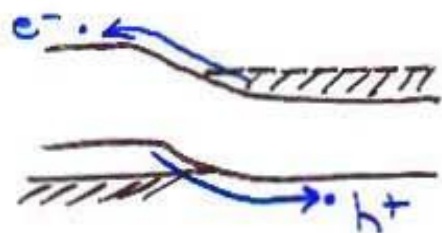


of states "opposite" (across junction at same energy) starts to decrease.

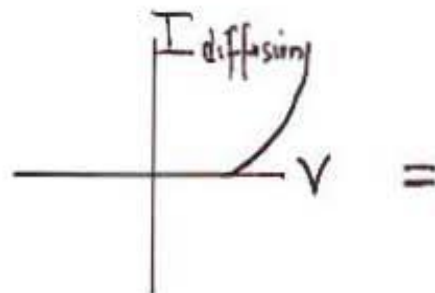
→ Tunnel current decreases with increasing forward bias.

$$J_{\text{Tunnel}} \sim \underbrace{f_n(E) N_{cn}(E)}_{\# \text{ filled on n-side}} \underbrace{(1 - f_p(E) N_{vp}(E))}_{\# \text{ empty on p-side}}$$

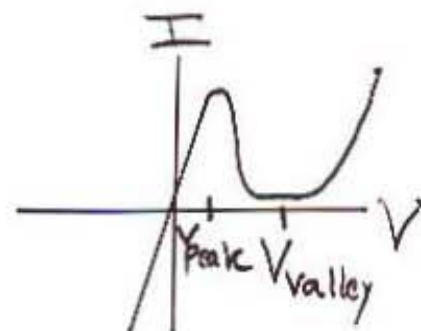
e.) Finally, diffusion dominates

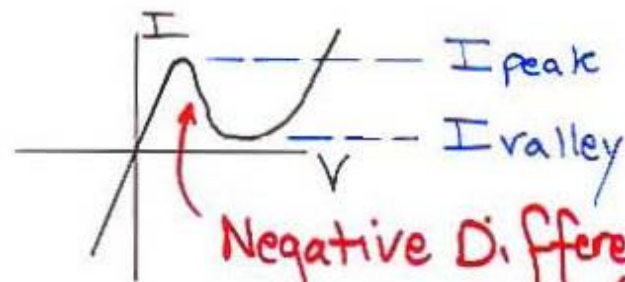


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S&B Figures 10-2, 10-3

Negative Differential Resistance (NDR) $\frac{dV}{dI} < 0$

- I_{peak} / I_{valley} is a figure of merit
- Determines slope of $\frac{dV}{dI}$ (magnitude of NDR)
- $V_{peak} / V_{valley} \rightarrow$ Voltage spread between positive $\frac{dV}{dI}$ regions

Applications: high speed circuits

- no time delays
- switching
- amplification
- but currents are low \rightarrow low power